Exercise 1 week 4

You want to measure the optical decay of a quantum dot sample. For this purpose you are using a Silicon pin photodiode which you hook up to a $50\,\Omega$ oscilloscope. The diode has an intrinsic region that is $25\,\mu m$ long, the diameter of the device is 1 mm and you are applying 5V in reverse bias. You excite the quantum dot with a repetition rate of 170 MHz (period 6 ns) and collect the quantum dot emission on the photodiode. A snapshot of the trace is shown in figure 1.

- a) Clearly the decay is biexponential. What is the decay time of the fast and slow component?
- b) Based on your knowledge of the response time of the photodiode; do you think these decay times represent a true process or could they be measurement artifacts?
- c) How could you improve the measurement?

For these questions you might need some material data which you find on the back.

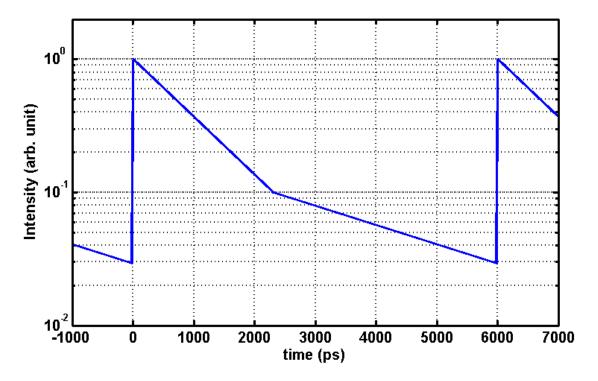
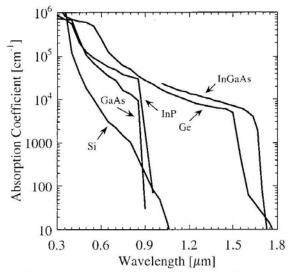
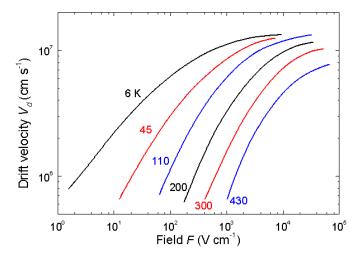


Figure 1

| Relative dielectric constant Refractive index near E_g Absorption coefficient near E_g | Electron effective mass Heavy hole effective mass | Electron affinity Minority carrier lifetime | Hole diffusion constant | Hole mobility Electron diffusion constant | Electron mobility | Effective DOS at VB edge | Effective DOS at CB edge | Intrinsic carrier concentration | Bandgap energy | Lattice constant | Gap: Direct (D) / Indirect (I) | Crystal structure | Quantity |
|--|--|---|-------------------------|--|-------------------|---|--------------------------|---------------------------------|----------------|------------------|------------------------------------|-------------------|----------|
| $\frac{\varepsilon_{r}}{n} =$ | $m_e^* = m_{hh}^* =$ | $=\frac{1}{\chi}$ | $D_{ m p}^{"}=$ | $D_{n} = D_{n}$ | $\mu_n =$ | $N_{_{\!$ | $N_{\rm c} =$ | $n_i =$ | $E_{\rm g} =$ | $a_0 =$ | | | Symbol |
| 11.9 3.3 10 ³ | $0.98 m_{\rm e} \\ 0.49 m_{\rm e}$ | $\frac{4.05}{10^{-6}}$ | 12 | 450 39 | 1500 | 1.0×10^{19} | 2.8×10^{19} | 1.0×10^{10} | 1.12 | 5.43095 | I | D | Si |
| 16.0 4.0 10 ³ | $1.64 m_{\rm e}$ $0.28 m_{\rm e}$ | $\frac{4.0}{10^{-6}}$ | 49 | 1900 101 | 3900 | 6.0×10^{18} | 1.0×10^{19} | 2.0×10^{13} | 0.66 | 5.64613 | I | D | Ge |
| 13.1 3.4 10 ⁴ | $0.067 m_{\rm e} \\ 0.45 m_{\rm e}$ | $\frac{4.07}{10^{-8}}$ | 10 | 400 220 | 8500 | 7.7×10^{18} | 4.4×10^{17} | 2.0×10^{6} | 1.42 | 5.6533 | D | Z | GaAs |
| ст <u>т</u> | 1 1 | s V | cm^2/s | $\frac{\text{cm}^2/\text{(Vs)}}{\text{cm}^2/\text{s}}$ | $cm^2/(Vs)$ | cm-3 | cm-3 | cm ⁻³ | eV | Å | 1 | ı | (Unit) |



Handbook of Optical Constants of Solids, edited by Edward D. Palik, (1985), Academic Press NY.



Drift velocities for Silicon, assume electrons and holes have the same velocity